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## Structure Reports

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## Key indicators

Single-crystal X-ray study
$T=295 \mathrm{~K}$
Mean $\sigma(\mathrm{C}-\mathrm{C})=0.003 \AA$
$R$ factor $=0.048$
$w R$ factor $=0.147$
Data-to-parameter ratio $=12.9$
For details of how these key indicators were automatically derived from the article, see http://journals.iucr.org/e.

[^0]
## 3-Chloroacetophenone 2,4,6-trinitrophenylhydrazone

Crystals of the title compound \{systematic name [(1E)-1-aza-2-(3-chlorophenyl)prop-1-enyl](2,4,6-trinitrophenyl)amine\}, $\mathrm{C}_{14} \mathrm{H}_{10} \mathrm{ClN}_{5} \mathrm{O}_{6}$, were obtained from a condensation reaction of 3-chloroacetophenone and 2,4,6-trinitrophenylhydrazine. There are two molecules in the asymmetric unit. The double bond in the bridge between the benzene rings displays an $E$ configuration. $\pi-\pi$ stacking is observed between parallel and nearly parallel benzene rings.

## Comment

As some phenylhydrazone derivatives have been shown to be potential DNA-damaging or mutagenic agents (Okabe et al., 1993), a series of nitrophenylhydrazone and dinitrophenylhydrazone derivatives has been synthesized in our laboratory in order to investigate the relationship between structure and bioactivity (Shan et al., 2003; Fan et al., 2004). As part of this ongoing work, we recently synthesized the title trinitrophenylhydrazone compound, (I), and present here its crystal structure.

(I)

There are two crystallographically independent molecules of (I) in the crystal structure (Fig. 1). Both molecule $A$ and molecule $B$ display an $E$ configuration, where the chlorophenyl and the trinitrophenyl rings are located on opposite sides of the $\mathrm{C}=\mathrm{N}$ double bonds $(\mathrm{N} 5=\mathrm{C} 8$ in $A$ and $\mathrm{N} 10=\mathrm{C} 22$ in $B$ ). This matches the configuration found in a related compound, 3-methoxyacetophenone 2,4,6-trinitrophenylhydrazone (Fan et al., 2005). In molecule B, the C15-C20 benzene plane is nearly parallel to the $\mathrm{C} 23-\mathrm{C} 28$ benzene plane [dihedral angle $5.65(18)^{\circ}$ ], but molecule $A$ displays a significantly more twisted conformation, with a dihedral angle of $11.26(25)^{\circ}$ between the C1-C6 and the C9-C14 planes. In molecule $A$, the N1-nitro group is nearly perpendicular to the C1-C6 benzene plane [dihedral angle $68.46(19)^{\circ}$ ]; a similar situation is observed in molecule $B$ [dihedral angle $70.9(2)^{\circ}$ ].



Figure 1
The asymmetric unit of (I), with $30 \%$ probability displacement ellipsoids and dashed lines indicating hydrogen bonds.


Figure 2
A diagram showing $\pi-\pi$ stacking [symmetry code: (i) $2-x, 1-y, 1-z$ ].

Figure 3


A diagram showing $\pi-\pi$ stacking [symmetry code: (ii) $x, \frac{3}{2}-y,-\frac{1}{2}+z$ ].


Figure 4
A diagram showing, with dashed lines, the shorter contacts between nonH atoms [symmetry code: (i) $2-x, 1-y, 1-z$ ].

This large out-of-plane twist reduces the repulsion between the hydrazone N atom and the adjacent nitro group.

Both the $\mathrm{C} 1-\mathrm{C} 2$ and $\mathrm{C} 1-\mathrm{C} 6$ bonds, which are adjacent to the imino N 4 atom, are significantly longer than the average distance of 1.375 (3) $\AA$ for the other $\mathrm{C}-\mathrm{C}$ bonds in the same benzene ring (Table 1 ), and this is also true for molecule $B$. This same pattern of distances was found in a previously reported trinitrophenylhydrazone compound (Fan et al., 2005).

An off-set overlapping arrangement of nearly parallel benzene planes is observed (Figs. 2 and 3). The centroid-tocentroid separations of 3.6638 (15) A between the C15-C20 and the $\mathrm{C} 23^{\mathrm{i}}-\mathrm{C} 28^{\mathrm{i}}$ benzene planes [symmetry code: (i) $2-x$, $1-y, 1-z$ ] and 3.6974 (14) $\AA$ between the C1-C6 and the $\mathrm{C} 9^{\mathrm{ii}}-\mathrm{C} 14^{\mathrm{ii}}$ benzene planes [symmetry code: (ii) $x, \frac{3}{2}-y,-\frac{1}{2}+z$ ] suggest the existence of $\pi-\pi$ stacking in the crystal structure of (I). This is also shown by a number of short (3.0-3.5 A) contacts between non-H atoms of neighboring molecules (Fig. 4 and Table 1).

## Experimental

2,4,6-Trinitrophenylhydrazine $(0.24 \mathrm{~g}, 1 \mathrm{mmol})$ was dissolved in ethanol $(18 \mathrm{ml})$ and acetic acid $(0.3 \mathrm{ml})$ was added slowly with stirring. The solution was heated at about 333 K for several minutes until it became clear. 3-Chloroacetophenone ( $0.16 \mathrm{~g}, 1 \mathrm{mmol}$ ) was added dropwise with continuous stirring, and the mixture was refluxed for 2 h . When the solution had cooled to room temperature, orange microcrystals appeared. The microcrystals were separated from the solution and washed with cold water three times. Recrystallization was performed twice with a solvent mixture of acetone/ethanol (3:1 v/ $v)$, to yield well shaped single crystals of (I).

## Crystal data

$$
\begin{aligned}
& \mathrm{C}_{14} \mathrm{H}_{10} \mathrm{ClN}_{5} \mathrm{O}_{6} \\
& M_{r}=379.72 \\
& \text { Monoclinic, } P 2_{1} / c \\
& a=13.1335(5) \AA \\
& b=24.5909(8) \AA \\
& c=10.0806(3) \AA \\
& \beta=104.328(2)^{\circ} \\
& V=3154.41(18) \AA^{3} \\
& Z=8
\end{aligned}
$$

$$
\begin{aligned}
& D_{x}=1.599 \mathrm{Mg} \mathrm{~m}^{-3} \\
& \text { Mo } K \alpha \text { radiation } \\
& \text { Cell parameters from } 12806 \\
& \quad \text { reflections } \\
& \theta=2.3-24.5^{\circ} \\
& \mu=0.29 \mathrm{~mm}^{-1} \\
& T=295(2) \mathrm{K} \\
& \text { Prism, yellow } \\
& 0.38 \times 0.36 \times 0.28 \mathrm{~mm}
\end{aligned}
$$

Data collection

Rigaku R-AXIS RAPID
diffractometer
$\omega$ scans
Absorption correction: none
25647 measured reflections
6085 independent reflections

4052 reflections with $I>2 \sigma(I)$
$R_{\text {int }}=0.046$
$\theta_{\text {max }}=25.9^{\circ}$
$h=-16 \rightarrow 16$
$k=-30 \rightarrow 30$
$l=-11 \rightarrow 12$

## Refinement

Refinement on $F^{2}$
$R\left[F^{2}>2 \sigma\left(F^{2}\right)\right]=0.048$
H -atom parameters constrained
$w R\left(F^{2}\right)=0.147$
$S=1.04$
6085 reflections
471 parameters
$w=1 /\left[\sigma^{2}\left(F_{\mathrm{o}}{ }^{2}\right)+(0.0873 P)^{2}\right]$
where $P=\left(F_{\mathrm{o}}{ }^{2}+2 F_{\mathrm{c}}{ }^{2}\right) / 3$
$(\Delta / \sigma)_{\max }=0.001$ 。
$\Delta \rho_{\max }=0.27 \mathrm{e} \AA^{-3}$
$\Delta \rho_{\text {min }}=-0.25 \mathrm{e}^{-3}$

Table 1
Selected interatomic distances $(\AA)$.

| $\mathrm{C} 1-\mathrm{N} 4$ | 1.350 (3) | C15-N9 | 1.349 (3) |
| :---: | :---: | :---: | :---: |
| C1-C2 | 1.413 (3) | C15-C16 | 1.423 (3) |
| C1-C6 | 1.417 (3) | C15-C20 | 1.413 (3) |
| C2-C3 | 1.363 (3) | C16-C17 | 1.364 (3) |
| C3-C4 | 1.382 (3) | C17-C18 | 1.376 (3) |
| C4-C5 | 1.362 (3) | C18-C19 | 1.368 (3) |
| C5-C6 | 1.389 (3) | C19-C20 | 1.381 (3) |
| C8-N5 | 1.295 (3) | C22-N10 | 1.287 (3) |
| $\mathrm{Cl} 2 \cdots \mathrm{~N} 7^{\mathrm{i}}$ | 3.430 (3) | $\mathrm{C} 27 \cdots \mathrm{~N} 8^{\text {i }}$ | 3.361 (4) |
| $\mathrm{C} 25 \cdots \mathrm{C} 9^{\text {i }}$ | 3.420 (4) | $\mathrm{N} 4 \cdots \mathrm{O}{ }^{\text {ii }}$ | 3.029 (3) |

Methyl H atoms were placed in calculated positions with $\mathrm{C}-\mathrm{H}=$ $0.96 \AA$ And torsionally refined to fit the electron density with $U_{\text {iso }}(\mathrm{H})=$ $1.5 U_{\text {eq }}(\mathrm{C})$. Other H atoms were placed in calculated positions with $\mathrm{C}-\mathrm{H}=0.93$ and $\mathrm{N}-\mathrm{H}=0.86 \AA$, and refined in the riding mode, with $U_{\text {iso }}(\mathrm{H})=1.2 U_{\text {eq }}$ (carrier).

Data collection: PROCESS-AUTO (Rigaku, 1998); cell refinement: PROCESS-AUTO; data reduction: CrystalStructure (Rigaku/ MSC and Rigaku, 2002); program(s) used to solve structure: SIR92 (Altomare et al., 1993); program(s) used to refine structure: SHELXL97 (Sheldrick, 1997); molecular graphics: ORTEP-3 for Windows (Farrugia, 1997); software used to prepare material for publication: WinGX (Farrugia, 1999).

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